	Application No.	Applicant(s)		
Notice of Allowability	10/604,225	CHANG, CHIH-CHI	CHANG, CHIH-CHIN	
	Examiner	Art Unit		
	Asok K. Sarkar	2829	m	
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.				
1. X This communication is responsive to amendment filed8/31.	<u>/2004</u> .			
2. The allowed claim(s) is/are 1-17 and 33-68.				
3. $igotimes$ The drawings filed on <u>02 July 2003</u> are accepted by the Ex	aminer.			
 4. Acknowledgment is made of a claim for foreign priority una) All b) Some* c) None of the: Certified copies of the priority documents have Certified copies of the priority documents have Copies of the certified copies of the priority documents have Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)). * Certified copies not received: Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. 	been received. been received in Application No. cuments have been received in this	s national stage applica		
5. A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give			IOTICE OF	
 CORRECTED DRAWINGS (as "replacement sheets") must (a) including changes required by the Notice of Draftspers 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examiner's Paper No./Mail Date ldentifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in the T. DEPOSIT OF and/or INFORMATION about the deposition of the position of the	son's Patent Drawing Review (PTC s Amendment / Comment or in the .84(c)) should be written on the draw he header according to 37 CFR 1.121	Office action of rings in the front (not the		
attached Examiner's comment regarding REQUIREMENT				
Attachment(s) 1. ☐ Notice of References Cited (PTO-892)	5 Notice of Informal	Datast Application /DT/	0.453)	
 Notice of References Cited (P10-692) Dotice of Draftperson's Patent Drawing Review (PT0-948) 	 5. ☐ Notice of Informal 6. ☐ Interview Summar 	• • • • • •	J-152)	
	Paper No./Mail D	ate		
 Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date 	8), 7. ⊠ Examiner's Amend	Iment/Comment		
4. Examiner's Comment Regarding Requirement for Deposit	8. X Examiner's Staten	nent of Reasons for Allo	wance	
of Biological Material	9.	9.		

Application/Control Number: 10/604,225 Page 2

Art Unit: 2829

DETAILED ACTION

Response to Amendment

1. Applicant's explanation of the instant invention in pointing the difference with the cited prior art was found to be persuasive.

EXAMINER'S AMENDMENT

2. The Applicant's representative was contacted in order to cancel the nonelected claims 18 – 32 since the election was made with traverse in response filed May 7, 2004. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Winston Hsu on September 20, 2004.

The application has been amended as follows:

Claims 18 – 32 have been cancelled.

Allowable Subject Matter

- 3. Claims 1 17 and 33 68 are allowed.
- 4. The following is an examiner's statement of reasons for allowance:

Claims 1 – 17 and 33 – 68 recite, inter alia, a method of forming a low temperature polysilicon (LTPS) TFT comprising the step of performing a trimming process to remove a certain width of the first patterned photo resist layer; removing the patterned conductive layer not covered by the first patterned photo resist layer to form

Application/Control Number: 10/604,225 Page 3

Art Unit: 2829

two second gaps and to define a gate of the N type LTPS TFT. The art of record does not disclose or anticipate the above limitation in combination with other claim elements nor would it be obvious to modify the art of record so as to form a device including the above limitation.

Conclusion

- 5. Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."
- 6. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Asok K. Sarkar whose telephone number is 571 272 1970. The examiner can normally be reached on Monday Friday (8 AM- 5 PM).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Michael Tokar can be reached on 571 272 1812. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

7. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only.

Application/Control Number: 10/604,225

Art Unit: 2829

,225

Page 4

For more information about the PAIR system, see http://pair-direct.uspto.gov. Should

you have questions on access to the Private PAIR system, contact the Electronic

Business Center (EBC) at 866-217-9197 (toll-free).

As the Univer Sarlier

Asok K. Sarkar September 20, 2004

Patent Examiner